



Contribution ID: 401

Type: Oral presentation (15min)

Enhancement of In-field J_c in $GdBa_2Cu_3O_{7-\delta}$ Coated Conductor by Using Highly Oriented IBAD Substrate

Tuesday 8 July 2014 11:45 (15 minutes)

For the improvement of J_c in rare-earth based superconducting coated conductor (CC), it is well established that highly oriented substrate is required because J_c across grain boundaries decreases significantly with increase of grain boundary angles. Typical value of the in-plane misalignment of Ion Beam Assisted Deposition (IBAD) substrate is around 3° where intra-grain J_c is almost the same level of inter-grain J_c at 77K, self-field. However, the effectiveness of highly oriented IBAD substrate on in-field J_c and its temperature dependence have not well clarified yet. In this study, we compared current transport properties in two $GdBa_2Cu_3O_{7-\delta}$ CCs deposited on different quality of IBAD templates, i.e., in-plane alignment of the substrate is 1.98° and 2.78° , respectively. From the comparison, J_c enhancement can be confirmed in wide temperature and magnetic field region in the sample using highly oriented IBAD substrate, whereas the irreversibility field doesn't change much. Macroscopic pinning force density curve of these two samples are similar, however, the maximum value of the pinning force density was increased. For the further understanding of the origin of J_c enhancement, we analyzed statistical distribution of J_c from E-J curve by using the percolation transition model. From the analysis, it can be seen that the minimum value of J_c distribution was increased as the substrate texturing is improved. These results indicate that the enhancement of in-field J_c comes from the improvement of grain connectivity. It should be noted that the improvement of in-plane texturing in the substrate is still very effective even in such range of 2 to 3° .

This work was supported by the METI: Development of Fundamental Technology for HTS Coils".

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Session Classification: Tue-Mo-Orals Session 3

Track Classification: M-02: RE123 conductors processing and properties